Fused silica transmission grating technology enables high resolution, high efficiency gratings that are ideal for compact spectrometers



Transmission gratings from Ibsen build on leadership in fused silica transmission grating technology. The superior performance of holography, combined with wafer-based Holostepper™ processing, makes possible high resolution, high efficiency, low noise gratings at the cost level of traditional reflection gratings.



Spectrometer Grating

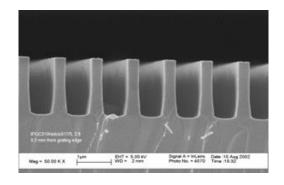
410 l/m for 1600 - 2500 nm

FSTG-XNIR410-937

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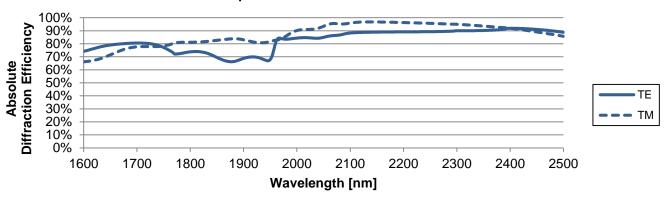
Benefits	
High diffraction efficiency combined with high dispersion	
Low polarization dependence over broad spectral range	
Unbeatable temperature and environmental tolerance	
Transmission configuration offers flexible and tolerant design	
Low stray light and low wavefront distortion	



Parameter	Specification
Materials	Fused silica and high-power, dielectric AR coating materials
Grating area	9.6 mm x 4.8 mm
Chip size	10 mm x 7 mm
Chip thickness	1.0 mm
Grating resolution	410 l/mm
Dispersion at 2000 nm	0.025 deg/nm
Angle of incidence (AOI)	26.8 deg
Illumination bandwidth	1600 – 2500 nm
Diffraction efficiency, unpolarized	>43%, 1600-2000 nm >63%, 2000-2500 nm
Coefficient of thermal expansion (CTE)	0.5 ppm/K
Maximum operating tempature	>500 degrees C
Cleaning recommendation	First contact. Available from Photonic Cleaning

Typical grating performance

FSTG-XNIR410-937 Dispersion: 0.025°/nm @ 2000 nm

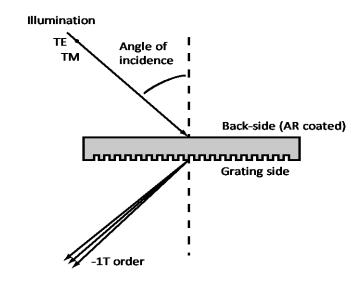




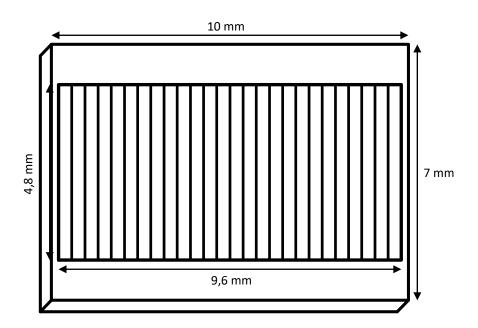
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Configuration/definitions



Drawing



Specifications are subject to change without notice.

The above grating is an example of Ibsen's capabilities. Ibsen operates as grating partner for our customers, from being an integrated part of the grating and device / instrument design phase, to the manufacturing of prototypes, to volume manufacturing of OEM gratings.

